AMENDMENTS TO THE CLAIMS:

Please cancel Claim 18 without prejudice to or disclaimer of the recited subject matter.

Please amend Claims 14 and 19 as follows.

1-13. (Cancelled)

14. (Currently Amended) A reflection type mask comprising:

a substrate on which a multi-layered film for reflecting X-rays is provided; a mask body including (a) a substrate, (b) a multi-layered film which is formed on said substrate, for reflecting X-rays, (c) a mask pattern which is formed on said multi-layered film for absorbing the X-rays; and

a cover for protecting said mask pattern,

wherein said cover is detachably attached to said substrate includes a vent hole having a lid openably closeable to said vent hole, and at least a part of said cover being arranged so as to be detachably attachable to said mask body.

- 15. (Previously Presented) A reflection type mask according to claim 14, further comprising an alignment mark formed on said multi-layered film.
- 16. (Previously Presented) A reflection type mask according to claim 14, further comprising an alignment mark, wherein said cover protects said alignment mark.

17. (Previously Presented) A reflection type mask according to claim 16, wherein said alignment mark is formed on said multi-layered film.

18. (Cancelled)

19. (Currently Amended) A reflection type mask according to claim 18-14, wherein said air through-hole vent hole is formed on a side surface of said cover.